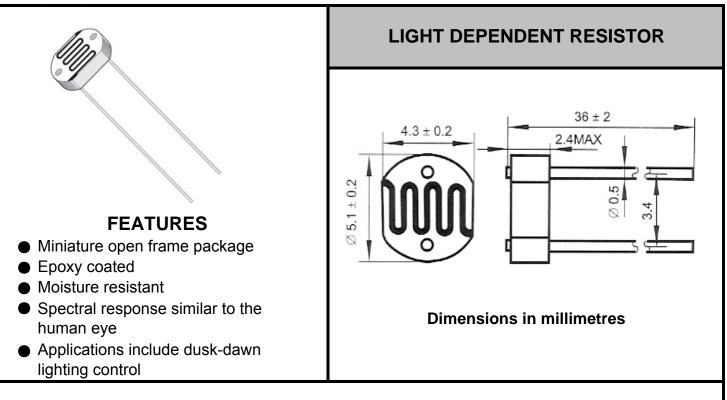


# 晶创和立科技

MINIATURE CADMIUM SULPHIDE PHOTOCONDUCTIVE CELL

CI



## SPECIFICATION AND PERFORMANCE

Model	Vmax (VDC)	Pmax (mW)	Ambient temp(℃)	Spectral peak (nm)	Light Resistance at 10Lux (KΩ)	Dark Resistance (MΩ)	Gamm a value at 100- 10Lux	Response Lime (ms)	
								Rise Time	Decay time
GL5616	150	90	-30~+70	560	5-10	2	0.75	30	30

**Relative Sensitivity (%)** 

100

80

60

40

20

**Spectral Response** 

# **Measuring Conditions**

#### 1. Light resistance:

Measured at 10 Lux with standard light A (2854K color temperature) and 2hr illumination at 400-600 lux prior to testing. **2. Dark Resistance:** Measured 10 senconds after closed 10 lux. **3. Gamma Characteristic:** Between 10 lux ande 100 lux and given by  $\gamma = lg(R10/R100)$ 

R10、R100 Cell resistance at 10 lux and 100 lux.

The error of  $\gamma$  is  $\pm$  0.1.

### 4. Pmax:

Max. power dissipation at ambient temperature of 25  $^\circ\!\mathbb{C}.$ 

#### 5. Vmax:

Max. voltage in darkness that may be applied to the cell continuously.



## 深圳市晶创和立科技有限公司 SHENZHEN JINGCHUANGHELI TECHNOLOGY CO., LTD.

0 400 500 600 700 800 900 1000

Wavelength (nm)

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#### Http://www.szichl.com E-mail:heli@szichl.com

ΚΩ 1000

100

10

1

10

100lux

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